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(54) Title: HYPOCHLOROUS ACID-BASED EYELID CLEANSERS

(57) Abstract: An antimicrobial eyelid cleanser composition contains hypochlorous acid, sodium acetate and purified water. The composition has a free available chlorine (FAC) concentration of from about 10 ppm - 300 ppm, an osmolality of 40-200 mOsm/kg and a viscosity of 1 cP - 500 cP. The composition has a pH from about 3.5 - 6.5. The eyelid cleanser composition is an ophthalmic or ocular composition that can clean the eyelids and eyes and remove excessive oil, debris, and desquamated skin from the eyelids and surrounding areas while reducing inflammation and promoting wound healing.



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